



Supporting Information

# Alkali-Etched NiCoAl-LDH with Improved Electrochemical Performance for Asymmetric Supercapacitors

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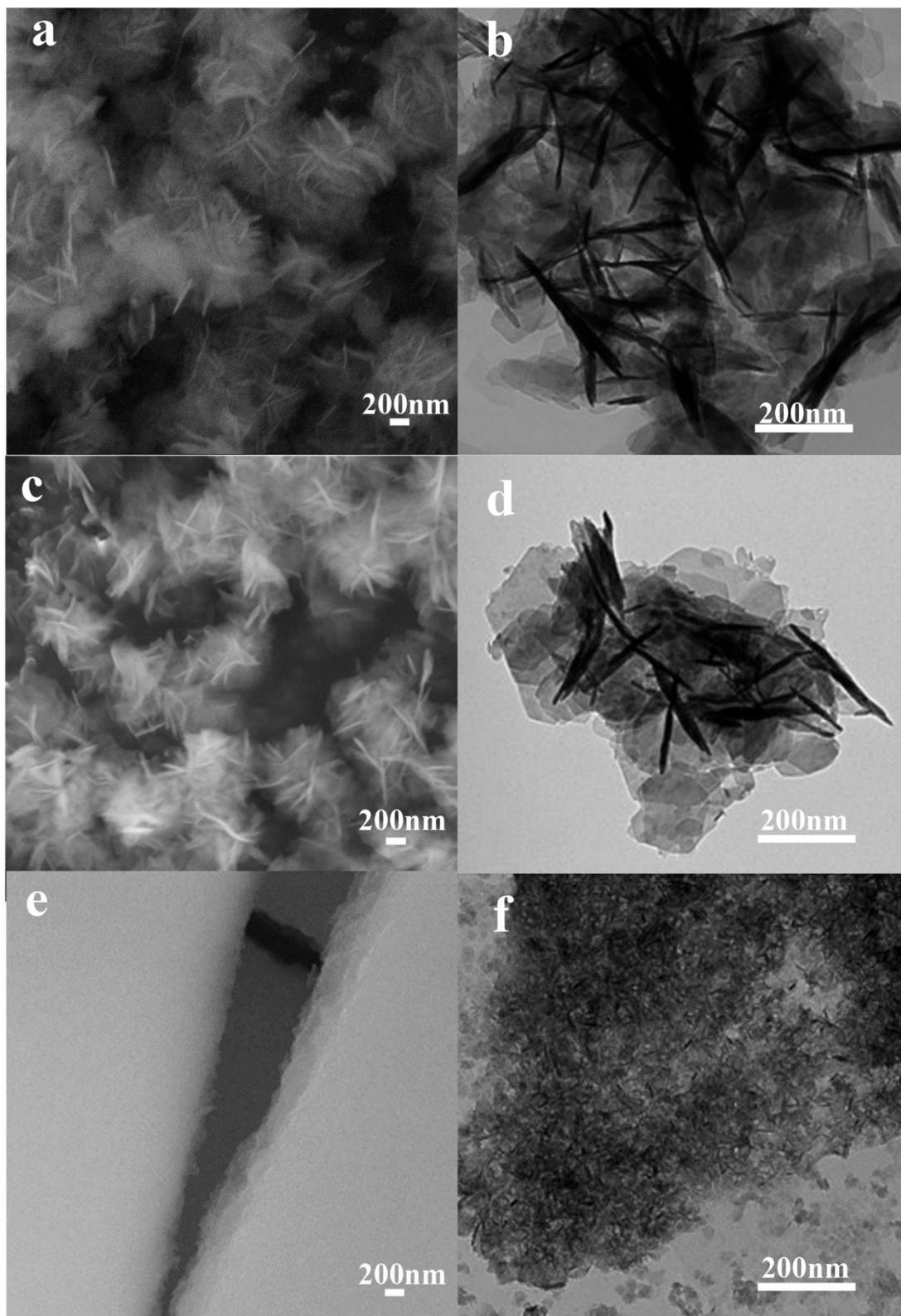
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**Figure S1.** (a) SEM of NiCoAl-921, (b) TEM of NiCoAl-921; (c) SEM of 6M NaOH etched NiCoAl-LDH, (d) TEM of 6M NaOH etched NiCoAl-LDH; (e) SEM of 10 M NaOH etched NiCoAl-LDH, (f) TEM of 10 M NaOH etched NiCoAl-LDH.

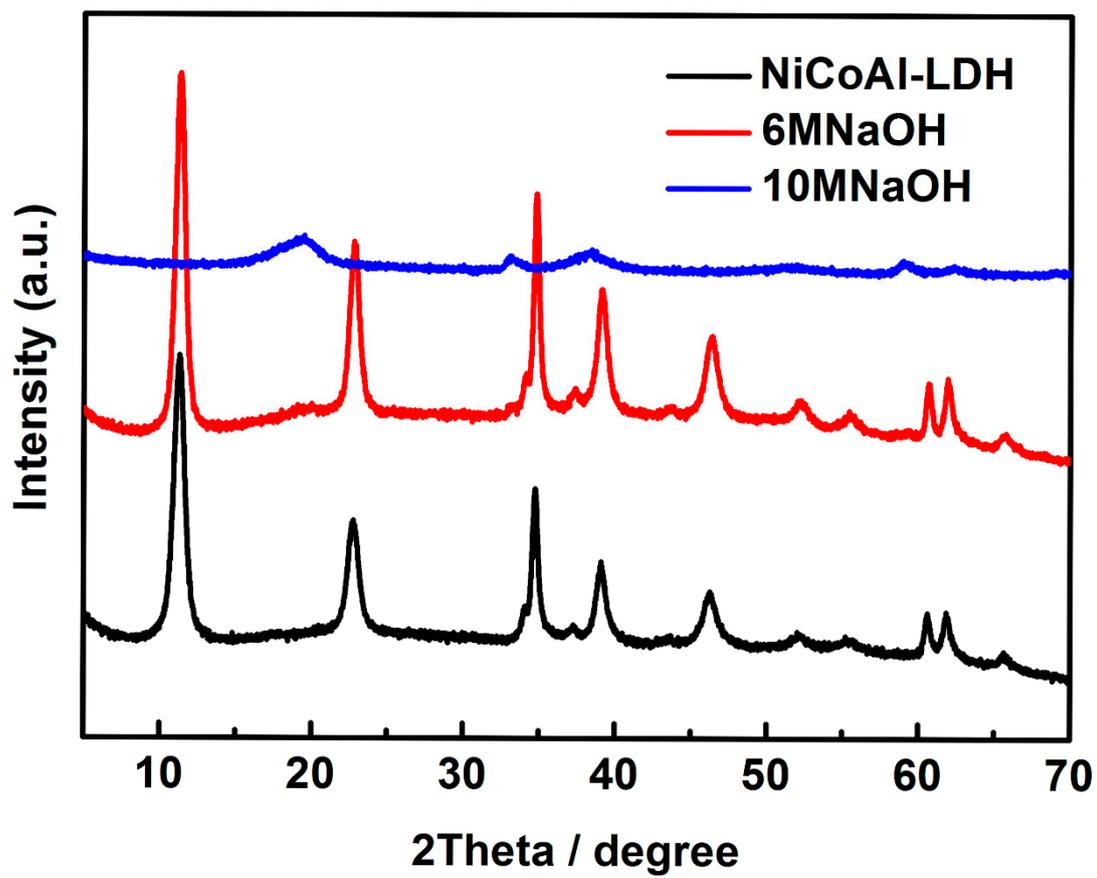


Figure S2. XRD pattern of alkali etching NiCoAl-LDH with different concentration.